Introduction to PLV Technology



SILICON LIGHT MACHINES

A SCREEN COMPANY

Silicon Light Machines Proprietary

Spatial Light Modulation at Silicon Light Machines



Grating Light Valve (GLV)

- Demonstrated in 1993
- HDTV display applications in 2000
- Computer to plate (CTP) printing in 2001
- Long-haul telecomm, dynamic gain equalizers (DGE) and re-configurable blocking filters (RBF) in 2002

Planar Light Valve (PLV)

- Conceived, modeled, and patented in 2003
- > DARPA contract for DUV maskless lithography 2004

Planar Light Valve Technology



- Silicon Light Machines conceived a 2D analog of the 1D GLV
- New device is based same CMOS process and materials used in the proven GLV technology, but arranges pixels in a 2-dimensional, close-packed array.
- New device inherits desirable properties of GLV and extends applications where GLV could not be used.
- Different embodiments of device can provide different modulation functionality: Amplitude, Phase, or Both

Planar Light Valve (PLV)





PLV Cross-Section





Device changes from reflective state to scattering state by deflection of the MEMS pistons through quarter wavelength.



Amplitude or Phase Modulation



A pixel, contrast only.



(a) Amplitude Modulator

A pixel, formed by 2×2 mirrors



(b) Amplitude+ Phase Modulator

- The piston structure of the PLV can support different embodiments depend on application requirement.
- By altering the piston-faceplate design, the PLV can be straightforwardly modified into a phase modulator.

Amplitude and Phase Modulation



Using this PLV structure, a single pixel can assign arbitrary amplitude and phase.

PLV Development Summary





Optical Response & Imaging





Silicon Light Machines Proprietary



